

Title (en)
PHOSPHATING METHOD

Publication
EP 0478028 A3 19920415 (DE)

Application
EP 91202119 A 19910820

Priority
DE 4029956 A 19900921

Abstract (en)
[origin: EP0478028A2] In the phosphating of metal surfaces composed at least partially of aluminium by means of zinc-, phosphate- and fluoride-containing phosphating solutions, titanium, which is absorbed by the phosphating solution and interferes with the layer formation, is precipitated by adding SiO-containing compounds and the required concentration of free fluoride is reestablished after the precipitate has been removed. <??>Particularly suitable SiO-containing compounds are alkali-metal metasilicate, orthosilicate and/or disilicate, preferably in an amount of 0.05 to 1 g/l of phosphating solution, or silicon dioxide, preferably in an amount of 0.5 to 10 g/l of phosphating solution (calculated in all cases as Si).

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C23C 22/86; **C23C 22/36**

IPC 8 full level
C23C 22/36 (2006.01); **C23C 22/86** (2006.01)

CPC (source: EP US)
C23C 22/362 (2013.01 - EP US); **C23C 22/86** (2013.01 - EP US)

Citation (search report)
• [A] DE 1521677 B1 19700430 - AMCHEM PROD
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Designated contracting state (EPC)
BE DE ES FR GB IT

DOCDB simple family (publication)
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